

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 10/537,363 Confirmation No. 3423  
Applicant : Wieve DE BOER  
Filed : June 2, 2005  
TC/A.U. : 1763  
Examiner : NG, James Wai Heung

Docket No. : US02 0527 US  
Customer No. : 65913

Title: SYSTEM AND METHOD FOR SUPPRESSION OF WAFER  
TEMPERATURE DRIFT IN COLD-WELL CVD SYSTEMS

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE & AMENDMENT**

Sir:

In response to the Office Action of September 24, 2007, please consider the following:

**Amendments to the Specification** there are no amendments in this paper.

**Amendments to the Claims** begin on page 2 of this paper.

**Remarks/Arguments** begin on page 4 of this paper.